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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM	FILING DATE	CLASS	SUBCLASS	GAU	EXAMINER
10054532	01/22/2002	430		1752	CLARK

**APPLICANTS: Lee Geun; Jung Jae; Shin Ki;

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**CONTINUING DATA VERIFIED:

NONE ^{yet}

** FOREIGN APPLICATIONS VERIFIED:

REPUBLIC OF KOREA 2001-38118 06/29/2001 ^{yes}

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		ATTORNEY DOCKET NO 30205/38083
35 USC 119 conditions met <input checked="" type="checkbox"/> yes <input type="checkbox"/> no		
Verified and Acknowledged Examiners's initials <input checked="" type="checkbox"/>		

TITLE : Photoresist monomers, polymers thereof and photoresist compositions containing the same

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
		Application Examiner	
<input type="checkbox"/> TERMINAL DISCLAIMER		PREPARED FOR ISSUE	
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